

KINTEK SOLUTION

## **Pecvd Machine Catalog**

Contact us for more catalogs of Sample Preparation, Thermal Equipment, Lab Consumables & Materials, Bio-Chem Equipment, etc...



### KINTEK SOLUTION

#### COMPANY PROFILE

#### >>> About Us

Kintek Solution Ltd is one technology orientated organization, team members are devoted to probing the most efficieent and reliable technology and innovations in the scienticfic researching equipment, fields like biochemical reacting, new materials researching, heat treatment, vaccum creating, refrigerating, as while as pharmaceutical and petroleum extracting equipment.

In the past 20 years, we earned rich experiences in this researing equipment field, we are capable to supply both the equipment and solution according to customer's needs and realities, we have also developed lots of customer tailer equipment accoding to a specific working purpose, and we have lots of successful projects in many universities and institutes from different countries, like Asia, Europe, North and south America, Australia and New Zealand, middle east, and Africa.

Profession, quick response, hard working, and sincerity is a remarkable label of our team meambers working attitude, which earn us a sound reputation among our clients.

We are here and ready to service our clients from different countries and regions, and share the most efficent and reliable technology together!





## Slide Pecvd Tube Furnace With Liquid Gasifier Pecvd Machine

**Item Number: KT-PE12** 



#### Introduction

KT-PE12 Slide PECVD System: Wide power range, programmable temp control, fast heating/cooling with sliding system, MFC mass flow control & vacuum pump.

Learn More

Furnace model	KT-PE12-60	
Max. temperature	1200℃	
Constant work temperature	1100°C	
Furnace tube material	High purity quartz	
Furnace tube diameter	60mm	
Heating zone length	1x450mm	
Chamber material	Japan alumina fiber	
Heating element	Cr2Al2Mo2 wire coil	
Heating rate	0-20°C/min	
Thermal couple	Build in K type	
Temperature controller	Digital PID controller/Touch screen PID controller	
Temperature control accuracy	±1℃	
Sliding distance	600mm	
RF Plasma unit		
Output Power	5 -500W adjustable with ± 1% stability	
RF frequency	13.56 MHz ±0.005% stability	
Reflection Power	350W max.	
Matching	Automatic	
Noise	<50 dB	
Cooling	Air cooling.	
Gas precise control unit		
Flow meter	MFC mass flow meter	
Gas channels	4 channels	
Flow rate	MFC1: 0-5SCCM 02 MFC2: 0-20SCMCH4 MFC3: 0- 100SCCM H2 MFC4: 0-500 SCCM N2	
Linearity	±0.5% F.S.	



Repeatability	±0.2% F.S.	
Pipe line and valve	Stainless steel	
Maximum Operating Pressure	0.45MPa	
Flow meter controller	Digital Knob controller/Touch screen controller	
Standard vacuum unit(Optional)		
Vacuum pump	Rotary vane vacuum pump	
Pump flow rate	4L/S	
Vacuum suction port	KF25	
Vacuum gauge	Pirani/Resistance silicon vacuum gauge	
Rated vacuum pressure	10Pa	
High vacuum unit(Optional)		
Vacuum pump	Rotary vane pump+Molecular pump	
Pump flow rate	4L/S+110L/S	
Vacuum suction port	KF25	
Vacuum gauge	Compound vacuum gauge	
Rated vacuum pressure	6x10-5Pa	

Above specifications and setups can be customized

No.	Description	Quantity
1	Furnace	1
2	Quartz tube	1
3	Vacuum flange	2
4	Tube thermal block	2
5	Tube thermal block hook	1
6	Heat resistant glove	1
7	RF plasma source	1
8	Precise gas control	1
9	Vacuum unit	1
10	Operation manual	1



## Inclined Rotary Plasma Enhanced Chemical Deposition (Pecvd) Tube Furnace Machine

**Item Number: KT-PE16** 



#### Introduction

Introducing our inclined rotary PECVD furnace for precise thin film deposition. Enjoy automatic matching source, PID programmable temperature control, and high accuracy MFC mass flowmeter control. Built-in safety features for peace of mind.

Learn More

Furnace model	PE-1600-60	
Max. temperature	1600°C	
Constant work temperature	1550°C	
Furnace tube material	High purity Al2O3 tube	
Furnace tube diameter	60mm	
Heating zone length	2x300mm	
Chamber material	Japan alumina fiber	
Heating element	Molybdenum Disilicide	
Heating rate	0-10°C/min	
Thermal couple	B type	
Temperature controller	Digital PID controller/Touch screen PID controller	
Temperature control accuracy	±1°C	
RF Plasma unit		
Output Power	$5$ -500W adjustable with $\pm$ 1% stability	
RF frequency	13.56 MHz ±0.005% stability	
Reflection Power	350W max.	
Matching	Automatic	
Noise	<50 dB	
Cooling	Air cooling.	
Gas precise control unit		
Flow meter	MFC mass flow meter	
Gas channels	4 channels	
Flow rate	MFC1: 0-5SCCM 02 MFC2: 0-20SCMCH4 MFC3: 0- 100SCCM H2 MFC4: 0-500 SCCM N2	
Linearity	±0.5% F.S.	



Repeatability	±0.2% F.S.	
Pipe line and valve	Stainless steel	
Maximum Operating Pressure	rating Pressure 0.45MPa	
Flow meter controller	Digital Knob controller/Touch screen controller	
Standard vacuum unit(Optional)		
Vacuum pump	Rotary vane vacuum pump	
Pump flow rate	4L/S	
Vacuum suction port	KF25	
Vacuum gauge	Pirani/Resistance silicon vacuum gauge	
Rated vacuum pressure	10Pa	
High vacuum unit(Optional)		
Vacuum pump	Rotary vane pump+Molecular pump	
Pump flow rate	4L/S+110L/S	
Vacuum suction port	KF25	
Vacuum gauge	Compound vacuum gauge	
Rated vacuum pressure	6x10-5Pa	
Above specifications and setups can be customized		

No.	Description	Quantity
1	Furnace	1
2	Quartz tube	1
3	Vacuum flange	2
4	Tube thermal block	2
5	Tube thermal block hook	1
6	Heat resistant glove	1
7	RF plasma source	1
8	Precise gas control	1
9	Vacuum unit	1
10	Operation manual	1



# Plasma Enhanced Evaporation Deposition Pecvd Coating Machine

**Item Number: KT-PED** 



#### Introduction

Upgrade your coating process with PECVD coating equipment. Ideal for LED, power semiconductors, MEMS and more. Deposits high-quality solid films at low temps.

Learn More

Sample holder	Size	1-6 inches
	Rotate speed	0-20rpm adjustable
	Heating temperature	≤800°C
	Control accuracy	±0.5°C SHIMADEN PID Controller
	Flow meter	MASS FLOWMETER CONTROLLER (MFC)
Gas purge	Channels	4 channels
	Cooling method	Circulating water cooling
	Chamber size	Φ500mm X 550mm
	Observation port	Full view port with baffle
	Chamber material	316 Stainless steel
Vacuum chamber	Door type	Front open type door
	Cap material	304 Stainless steel
	Vacuum pump port	CF200 flange
	Gas inlet port	φ6 VCR connector
	Source power	DC power or RF power
DI.	Coupling mode	Inductively coupled or plate capacitive
Plasma power	Output power	500W—1000W
	Bias power	500v
	Pre- pump	15L/S Vane vacuum pump
	Turbo pump port	CF150/CF200 620L/S-1600L/S
	Relief port	KF25
Vacuum pump	Pump speed	Vane pump:15L/s[Turbo pump:1200l/s[]1600l/s
	Vacuum degree	≤5×10-5Pa
	Vacuum sensor	lonization/resistance vacuum gauge/film gauge
System	Electric power supply	AC 220V /380 50Hz



5kW Rated power

200kg Weight



### Rf Pecvd System Radio Frequency Plasma-Enhanced Chemical **Vapor Deposition**

**Item Number: KT-RFPE** 



#### Introduction

RF-PECVD is an acronym for "Radio Frequency Plasma-Enhanced Chemical Vapor Deposition." It deposits DLC (Diamond-like carbon film) on germanium and silicon substrates. It is utilized in the 3-12um infrared wavelength range.

Learn More

Equipment form

Vacuum chamber

- Box type: the horizontal top cover opens the door, and the deposition chamber and the exhaust chamber are integrally welded;
- The whole machine: the main engine and the electric control cabinet are integrated design (the vacuum chamber is on the left, and the electric control cabinet is on the right).
- Dimensions: Φ420mm (diameter) × 400 mm (height); made of 0Cr18Ni9 high-quality SUS304 stainless steel, the inner surface is polished, fine workmanship is required without rough solder joints, and there are cooling water pipes on the chamber wall;
- Air extraction port: Double-layer 304 stainless steel mesh with 20mm front and rear intervals, anti-fouling baffle on the high valve stem, and air equalization plate at the exhaust pipe mouth to prevent pollution;
- · Sealing and shielding method: the upper chamber door and the lower chamber are sealed by a sealing ring to seal the vacuum, and the stainless steel network tube is used outside to isolate the radio frequency source, shielding the harm caused by radio frequency signals to people;
- · Observation window: Two 120mm observation windows are installed on the front and side, and the anti-fouling glass is resistant to high temperature and radiation, which is convenient for observing the substrate;
- Air flow mode: the left side of the chamber is pumped by the molecular pump, and the right side is the air inflated to form a convective working mode of charging and pumping to ensure that the gas flows evenly to the target surface and enters the plasma area to fully ionize and deposit the carbon film:
- Chamber material: the vacuum chamber body and the exhaust port are made of OCr18Ni9 high-quality SUS304 stainless steel material, the top cover is made of high-purity aluminum to reduce the weight of the top.

Host skeleton

• Made of section steel (material: Q235-A) , the chamber body and the electric control cabinet are integrated design.

Water cooling

system

- Pipeline: The main inlet and outlet water distribution pipes are made of stainless steel pipes; • Ball valve: All cooling components are supplied with water separately through 304 ball valves, and the water inlet and outlet pipes have color distinctions and corresponding signs, and the 304 ball valves for the water outlet pipes can be opened and closed separately; The target, RF power supply, chamber wall, etc. are equipped with water flow protection, and there is a water cut-off alarm to prevent the water pipe from being blocked. All water flow alarms are displayed on the industrial computer;
- Water flow display: The lower target has water flow and temperature monitoring, and the temperature and water flow are displayed on the industrial computer:
- Cold and hot water temperature: when the film is deposited on the chamber wall, cold water is passed through 10-25 degrees to cool the water, and it is advanced when the chamber door is opened. Pass hot water 30-55 degrees warm water

Control cabinet

- Structure: vertical cabinets are adopted, the instrument installation cabinet is a 19-inch international standard control cabinet, and the other electrical component installation cabinet is a large panel structure with a rear door;
- Panel: The main electrical components in the control cabinet are all selected from manufacturers that have passed CE certification or ISO9001 certification. Install a set of power sockets on the panel:
- Connection method: the control cabinet and the host are in a conjoined structure, the left side is the room body, the right side is the control cabinet, and the lower part is equipped with a dedicated wire slot, high and low voltage, and the RF signal is separated and routed to reduce
- Low-voltage electrical: French Schneider air switch and contactor to ensure reliable power supply of equipment;
- Sockets: Spare sockets and instrumentation sockets are installed in the control cabinet.



	Solution for researching
Ultimate vacuum	• Atmosphere to 2×10-4 Pa≤24 hours, (at room temperature, and the vacuum chamber is clean).
Restore vacuum time	• Atmosphere to 3×10 -3 Pa≤15 min (at room temperature, and the vacuum chamber is clean, with baffles, umbrella stands, and no substrate).
Pressure rise rate	• ≤1.0×10 -1 Pa/h
Vacuum system configuration	<ul> <li>The composition of the pump set: backing pump BSV30 (Ningbo Boss) + Roots pump BSJ70 (Ningbo Boss) + molecular pump FF-160 (Beijing);</li> <li>Pumping method: pumping with soft pumping device (to reduce the pollution to the substrate during pumping);</li> <li>Pipe connection: the vacuum system pipe is made of 304 stainless steel, and the soft connection of the pipe is made of;</li> <li>Metal bellows; each vacuum valve is a pneumatic valve;</li> <li>Air suction port: In order to prevent the membrane material from polluting the molecular pump during the evaporation process and improve the pumping efficiency, a movable isolation plate that is easy to disassemble and clean is used between the air suction port of the chamber body and the working room.</li> </ul>
Vacuum system measurement	<ul> <li>Vacuum display: three lows and one high (3 groups of ZJ52 regulation + 1 group of ZJ27 regulation);</li> <li>High-vacuum gauge: ZJ27 ionization gauge is installed on the top of the pumping chamber of the vacuum box near the working chamber, and the measuring range is 1.0×10 -1 Pa to 5.0×10 -5 Pa;</li> <li>Low-vacuum gauges: one set of ZJ52 gauges is installed on the top of the pumping chamber of the vacuum box, and the other set is installed on the rough pumping pipe. The measuring range is 1.0×10 +5 Pa to 5.0×10 -1 Pa;</li> <li>Working regulation: CDG025D-1 capacitive film gauge is installed on the chamber body, and the measuring range is 1.33×10 -1 Pa to 1.33×10 +2 Pa, vacuum detection during deposition and coating, used in conjunction with constant vacuum butterfly valve use.</li> </ul>
Vacuum system operation	<ul> <li>There are two modes of vacuum manual and vacuum automatic selection;</li> <li>Japan Omron PLC controls all the pumps, the action of the vacuum valve, and the interlocking relationship between the work of the inflation stop valve to ensure that the equipment can be automatically protected in case of misoperation;</li> <li>High valve, low valve, pre-valve, high valve bypass valve, in-position signal is sent to PLC control signal to ensure more comprehensive interlock function;</li> <li>The PLC program can carry out the alarm function of each fault point of the whole machine, such as air pressure, water flow, door signal, over-current protection signal, etc. and alarm, so that the problem can be found quickly and conveniently;</li> <li>The 15-inch touch screen is the upper computer, and the PLC is the lower computer monitoring and control valve. Online monitoring of each component and various signals are sent back to the industrial control configuration software in time for analysis and judgment, and recorded;</li> <li>When the vacuum is abnormal or the power is cut off, the molecular pump of the vacuum valve should return to the closed state. The vacuum valve is equipped with an interlock protection function, and the air inlet of each cylinder is equipped with a cut-off valve adjustment device, and there is a position set the sensor to display the closed state of the cylinder;</li> </ul>
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• According to the general technical conditions of GB11164 vacuum coating machine.





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